Substitute for form 1449/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

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Sheet	1	of	1

Complete if Known				
Application Number	10/722,576			
Filing Date	November 28, 2003			
First Named Inventor	Thomas Happ			
Art Unit	2187	<i>e</i> *		
Examiner Name	K. N. McLean Mayo			
Attorney Docket Number	543822002600			

U.S. PATENT DOCUMENTS						
	Cite	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
	No.1	Number-Kind Code ² (if known)				
	1.	2003/0084233-A1	05-01-2003	WILLIAMS .		

FOREIGN PATENT DOCUMENTS						
Examiner Cite Initials* No.1	Cite	Foreign Patent Document	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
		Country Code ³ -Number ⁴ -Kind Code ⁵ (if known)		Applicant of Cited Document		Т6
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NON PATENT LITERATURE DOCUMENTS					
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), yolume-issue number(s), publisher, city and/or country where published.	T²		
	2.	Hirose, Y. et al. (1976). "Polarity-dependent Memory Switching and Behavior of Ag Dendrite in Ag-photodoped Amorphous As ₂ S ₃ Films," <i>Journal of Applied Physics</i> 47(6):2767-2772.			
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V2-18076	37		

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